



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Hiroshi TAKANASHI et al.

Serial No. 09/838,118 ✓

Filed April 20, 2001

NEGATIVE-WORKING PHOTORESISTIVE
RESIN COMPOSITION AND
PHOTORESISTIVE RESIN PLATE
USING THE SAME

Confirmation No. 9938

Docket No. 2001_0476

Group Art Unit 1752

Examiner S. Lee

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**RESPONSE UNDER 37. CFR 1.116
EXPEDITED PROCEDURE
EXAMINING GROUP 1752**

RESPONSE UNDER 37 C.F.R. 1.116

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Final Rejection dated March 20, 2003, the period for response having been extended for three months by the attached petition, please amend the present application as follows: